



Docket No.: 055071-0267

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of	:	Customer Number: 20277
	:	
Stephen D. HSU, et al.	:	Confirmation Number: 9799
	:	
Application No.: 10/626,858	:	Group Art Unit: 2825
	:	
Filed: July 25, 2003	:	Examiner: PARIHAR, Suchin
	:	
For: ORIENTATION DEPENDENT SHIELDING FOR USE WITH DIPOLE ILLUMINATION TECHNIQUES		

**INFORMATION DISCLOSURE STATEMENT**

Mail Stop Information Disclosure Statement  
Honorable Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed more than three months after the U.S. filing date AND after the mailing date of the first Office Action on the merits, but before the mailing date of a Final Rejection or Notice of Allowance.

To the extent necessary, a petition for an extension of time under 37 C.F.R. 1.136 is hereby made. Please charge any shortage in fees due in connection with the filing of this paper,

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**10/626,858**

including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

McDERMOTT WILL & EMERY LLP



Michael E. Fogarty

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**Please recognize our Customer No. 20277  
as our correspondence address.**

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**Date: April 14, 2006**

SHEET 1 OF 1INFORMATION DISCLOSURE  
CITATION IN AN  
APPLICATION

(PTO-1449)

ATTY. DOCKET NO.  
**055071-0267**SERIAL NO.  
**10/626,858**

APPLICANT

**Stephen D. HSU, et al.**FILING DATE  
**July 25, 2003**GROUP  
**2825**

## U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Code <sup>2</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		US 6,851,103 B2	Feb. 1, 2005	Van Den Broeke et al.	
		US 6,915,505 B2	Jul. 5, 2005	Hsu et al.	
		US 6,875,545 B2	Apr. 5, 2005	Eurlings et al.	
		US			
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## FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes-Number 4-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation	
						Yes	No
		EP 1 091 252 A2	04-11-2001			X	
		EP 1 152 289 A2	11-07-2001			X	
		EP 1 152 289 A3	11-07-2001			X	

## OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.
		"Mask Topography Effects in Projection Printing of Phase-Shifting Masks", Alfred K. Wong and Andrew R. Neureuther, Fellow, IEEE Transactions on Electron Devices, Vol. 41, No. 6, June 1994
		"Spatial Frequency Doubling Lithography (SFDL) of Periodic Structures for Integrated Optical Circuit Technology", Tanya E. Jewell and Donald L. White. Journal of Lightwave Technology, Vol. 7, No. 9, September 1989

EXAMINER

DATE CONSIDERED

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.